## Abstract Submitted for the MAR17 Meeting of The American Physical Society

Enhancement of hidden order and antiferromagnetism in Fe and Os substituted URu<sub>2</sub>Si<sub>2</sub> under pressure. CHRISTIAN WOLOWIEC, NORAVEE KANCHANAVATEE, KEVIN HUANG, SHENG RAN, M. BRIAN MAPLE, Univ of California - San Diego — We present electrical resistivity measurements made under pressure for the Fe and Os substituted URu<sub>2</sub>Si<sub>2</sub>. The parent compound  $URu_2Si_2$  exhibits a hidden order (HO) phase below  $T_0$ ambient pressure. A phase transition from HO to a large moment antiferromagnetic (LMAFM) phase is induced by applying pressure P or by substituting Fe or Os for Ru ions. While the substitution of smaller Fe ions reduces the unit cell volume thus creating a positive chemical pressure  $P_{ch}$ , the substitution of larger Os ions results in a negative  $P_{\rm ch}$ . As Fe concentration (x) is increased, the critical pressure  $P_{\rm c}$  forcing the HO to LMAFM phase transition is reduced from 1.4 GPa at x = 0 to 0 GPa = 0.15. By converting x to  $P_{\rm ch}(x)$ , we found that  $P_{\rm ch}(x)$  +  $P_{\rm c}$   $\approx 1.5$ GPa at the phase transition. These results suggest that  $P_{\rm ch}$  behaves like external Pin inducing the HO  $\rightarrow$  LMAFM phase transition. However, we also found that as the Os concentration (y) is increased, a smaller  $P_c$  is required to induce the HO  $\rightarrow$ LMAFM phase transition:  $P_c \sim 1.4$  GPa at y = 0 reduces to  $P_c \sim 0$  GPa = 0.065. This is contrary to what one would expect from a negative  $P_{\rm ch}$ effect. Hence, the Os substitution study suggests that  $P_{\rm ch}$  is not solely responsible for inducing the LMAFM phase.

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